

# (12) United States Patent Lin et al.

### US 9,543,454 B1 (10) Patent No.:

### (45) Date of Patent: Jan. 10, 2017

### (54) DIODES WITH MULTIPLE JUNCTIONS

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(\*) Notice: Subject to any disclaimer, the term of this

patent is extended or adjusted under 35

U.S.C. 154(b) by 0 days.

(21) Appl. No.: 14/832,379

(22) Filed: Aug. 21, 2015

(51)	Int. Cl.	
` ′	H01L 29/861	(2006.01)
	H01L 31/107	(2006.01)
	H01L 23/58	(2006.01)
	H01L 27/082	(2006.01)
	H01L 27/102	(2006.01)
	H01L 29/70	(2006.01)
	H01L 31/11	(2006.01)
	H01L 29/866	(2006.01)
	H01L 29/66	(2006.01)
	H01L 29/06	(2006.01)
	H01L 21/266	(2006.01)
	H01L 21/265	(2006.01)

(52) U.S. Cl. CPC ........... H01L 29/866 (2013.01); H01L 21/266 (2013.01); H01L 21/26513 (2013.01); H01L 29/0615 (2013.01); H01L 29/0649 (2013.01); H01L 29/66106 (2013.01)

#### (58)Field of Classification Search

CPC .. H01L 29/866; H01L 29/73; H01L 29/66121; H01L 29/861 See application file for complete search history.

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### **ABSTRACT**

A diode includes a semiconductor substrate having a surface; a first contact region disposed at the surface of the semiconductor substrate and having a first conductivity type; and a second contact region disposed at the surface, laterally spaced from the first contact region, and having a second conductivity type. The diode also includes a buried region disposed in the semiconductor substrate vertically adjacent to the first contact region, having the second conductivity type, and electrically connected with the second contact region; and an isolation region disposed at the surface between the first and second contact regions. The diode also includes a separation region disposed at the surface between the first contact region and the isolation region, the separation region formed from a portion of a first well region disposed in the semiconductor substrate that extends to the surface.

## 15 Claims, 15 Drawing Sheets



